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\*Admitted only in Maryland  
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\*Practice limited to  
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**Art Unit 1797**  
**Confirmation No.: 5840**  
**Attn: Mail Stop Amendment**

Re: U.S. Utility Patent Application  
Application No. 10/529,765; Filing or 371(c) Date: November 3, 2005  
For: **Cleaning Device for Cleaning Process Gas of a Reflow Soldering System**  
Inventors: MEIER *et al.*  
Our Ref: 2380.0010000

Sir:

Transmitted herewith for appropriate action is the following document:

1. Amendment & Reply Under 37 C.F.R. § 1.111 Responsive to Office Action dated July 1, 2009.

***The above-listed document is being filed electronically through EFS-Web.***

In the event that extensions of time are necessary to prevent abandonment of this patent application, then such extensions of time are hereby petitioned.

The U.S. Patent and Trademark Office is hereby authorized to charge any fee deficiency, or credit any overpayment, to our Deposit Account No. 19-0036.

Respectfully submitted,

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Enclosure(s)  
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